

## **REMARKS**

Claims 3 and 15 have been amended to clarify the claimed compositions of the dielectric films. In claim 3, the composition of the silicon oxynitride comprises either a silicon oxide having a specific ratio range of silicon and oxygen OR a silicon nitride having specific ratio of silicon and nitrogen. Because neither claims 1 or 2 claim the presence of a silicon oxynitride, it is believed that there is no duplication of limitations between claims 1, 2 and 3. By the same reasoning, the composition of the silicon oxynitride in claim 15 comprises either a silicon oxide having a specific ratio range of silicon and oxygen OR a silicon nitride having specific ratio of silicon and nitrogen. This clarifying amendment is in response to further discussions with the inventor's representative and is believed to both address the Examiner's expressed concerns and not introduce new matter into the application. Given the previous indication of allowable subject matter and the resolution of the Examiner's concerns over limitation duplication, applicants believe that the application is in condition for allowance.

Upon receipt of the Notice of Allowance, applicants will revised the specification and Abstract to conform to the allowed subject matter combinations. At that time, applicants will also address any translation artifacts that may exist in the application. Applicants believe that no fees are due. However, should any additional fees be required, please charge them to Deposit Account No. 07-1897.

DATED this 3<sup>rd</sup> day of March, 2006.

Respectfully submitted,

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